

# 光刻胶用户调查表

尊敬的用户:

感谢您对我公司光刻胶产品的支持!

为了方便您选择适当的型号,请您填写下面的表格并发送给我们,我们会尽快与您联系!

您的姓名: ..... 所属行业/单位: .....  
您的电话: ..... 您的传真: .....  
您的 Email: .....  
您的邮政地址: .....

Photolithography       E-beam lithography       Mix & match  
 I-line (365nm)       G-line (436nm)       Other wavelength \_\_\_\_\_

**Substrate**       silicon       SiO<sub>2</sub>/glass       \_\_\_\_\_  
**Kind of image**       negative       positive       image reversal  
**Kind of coating**       spin coating       dip coating       spray coating  
**Layer thickness**       \_\_\_\_\_ μm       \_\_\_\_\_ μm  
**Structure width**       >5μm       ≤2μm       \_\_\_\_\_ μm  
**Contrast**       small(<1μm)       medium(1-3)       high(>3)  
**Process of etching**       medium(1-3)       PH \_\_\_\_\_       plasma \_\_\_\_\_  
**Edge profile**       <85°       85-90°       undercut  
**Other Requirements**      \_\_\_\_\_

colouring against stray radiation and standing waves  
 high adhesion       high adhesion  
 high adhesion       edge covering of pronounced topologies

## Application

Mask, optical application       MEMS       LIGA       LED, OLED  
 \_\_\_\_\_

## Annual Consumption

< 1 liter       1~5 liter       5~10 liter       10~20 liter       \_\_\_\_\_

Your suggestions are always of particular importance for our work. Do you have any further requirements, suggestions for improvement, or requests concerning products or service?